

Electronic Supplementary Material

Graphene-like *h*-BN supported polyhedral NiS₂/NiS nanocrystals with excellent photocatalytic performance for removing rhodamine B and Cr(VI)

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In the work, NiS₂/NiS as a mixed crystal, the band gap energy of NiS and NiS₂ can't be separately measured. So we found new methods to prepare pure NiS nanoparticles and polyhedral NiS₂ [1,2]. Fig. S1 shows VB spectra of *h*-BN, NiS and NiS₂. XPS valence band spectra were further measured to estimate the valence band (VB) positions of *h*-BN, NiS and NiS₂. The VB of *h*-BN (3.47 eV) (Fig. S1a), NiS (0.77 eV) (Fig. S1b) and NiS₂ (1.24 eV) (Fig. S1c) is basically in line with that in schematic mechanism (*h*-BN (3.51 eV), NiS (0.53 eV) and NiS₂ (1.19 eV)). In addition, the flat-band potential were investigated by the Mott-Schottky curve (Fig. S2). The plot slope of NiS, NiS₂/NiS and 7 wt.% *h*-BN/NiS₂/NiS was negative, while the plot slope of NiS₂ and *h*-BN was positive, indicating that the former is p-type semiconductor and the latter is n-type material [3,4]. Furthermore, as revealed, the flat-band potential of the *h*-BN (n-type material) [5] and other samples are -0.82 eV (*h*-BN, vs AgCl) (Fig. S2a), 0.84 eV (NiS, vs AgCl) (Fig. S2b), -0.84 eV (NiS₂, vs

AgCl) (Fig. S2c), 1.01 eV (NiS₂/NiS, vs AgCl) (Fig. S2d), and 1.04 eV (7 wt.% *h*-BN/NiS₂/NiS, vs AgCl) (Fig. S2e), respectively. Corrected by the AgCl (vs 0.197 eV), the Fermi level of the samples could be calculated to be -0.623 eV (*h*-BN, vs NHE), -0.643 eV (NiS, vs NHE), -0.643 eV (NiS₂, vs NHE), -0.804 eV (NiS₂/NiS, vs NHE), and -0.843 eV (7 wt.% *h*-BN/NiS₂/NiS, vs NHE), respectively. As revealed, the $E_f\text{-NiS} = E_f\text{-NiS}_2 < E_f\text{-NiS}_2/\text{NiS} < E_f\text{-}h\text{-BN} < E_f\text{-7 wt.\% } h\text{-BN/NiS}_2/\text{NiS}$, which indicates that the photon-generated electron would transfer along the route of the NiS, NiS₂ to *h*-BN, that process could promote the separation, transferring and diffusion of the photon-generated carriers efficiently, and the result is in line with XPS.

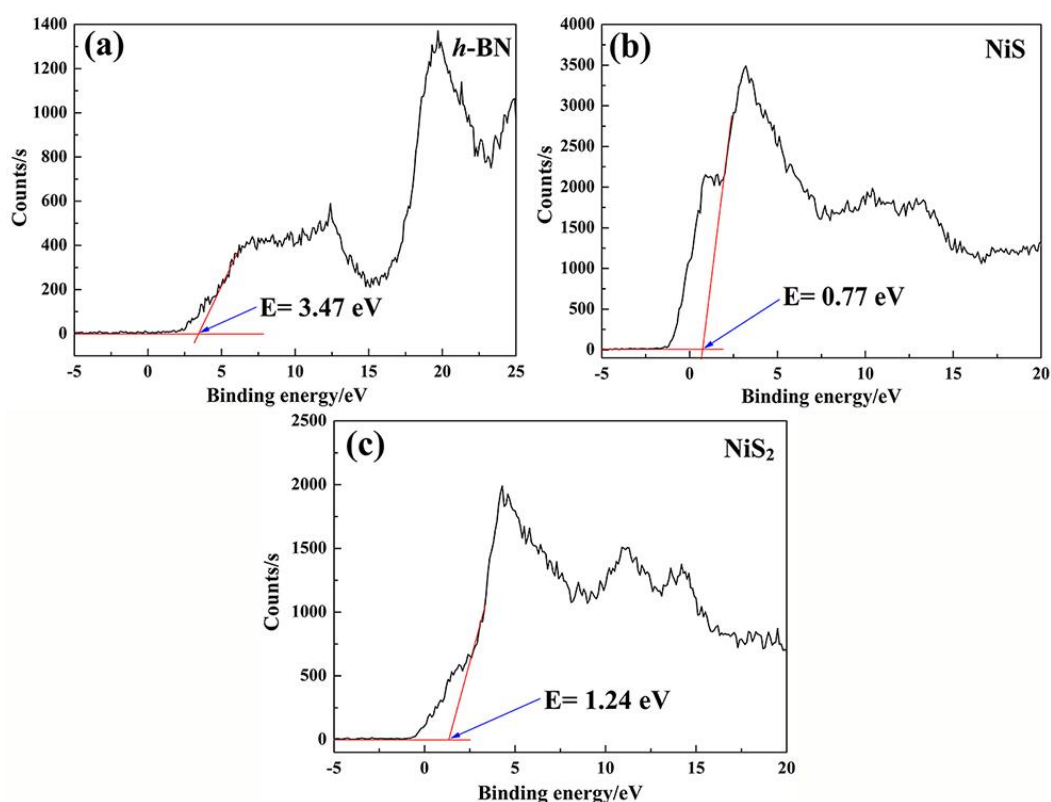


Fig. S1 VB XPS spectra of (a) *h*-BN; (b) NiS; (c) NiS₂.

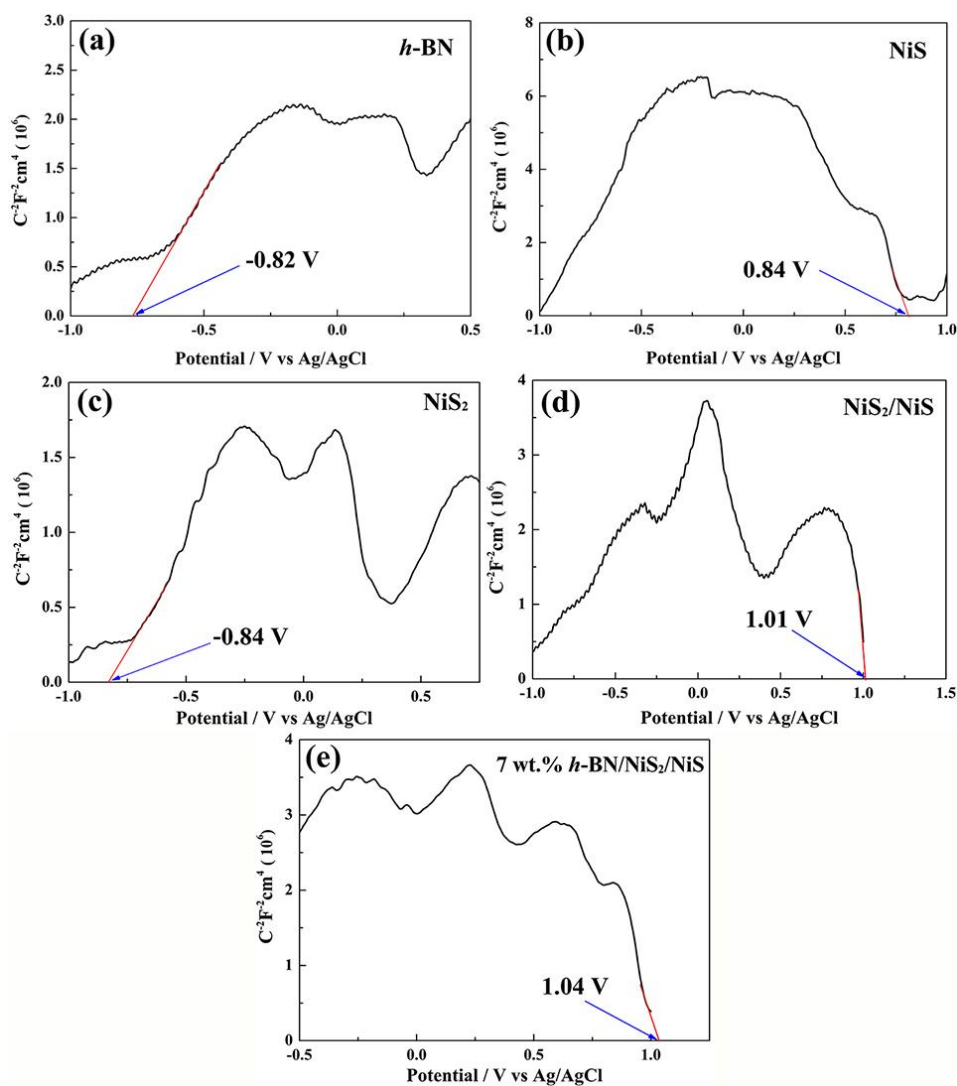


Fig. S2 The Mott-schottky plots of the different samples.

References

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